## **Information on Search Strategy** - Pilot phase (see OJ 2015, A86) The type of information contained in this sheet may change during the pilot for improving the usefulness of this new service.

**Application Number** 

PCT/GE2019/050002

TITLE: METHOD FOR PRODUCTION OF NANOMATERIAL IN VACUUM AND MAGNETRON SPATTERING

DEVICE FOR ITS EMBODIMENT

APPLICANT: BERISHVILI, Zaur

IPC CLASSIFICATION: C23C14/35, H01J37/34

EXAMINER: Remy, Jérôme

CONSULTED DATABASES: NPL, COMPDX, DOSYS, EPODOC, PHOTO, TDB, WPI, XPAIP, XPESP,

XPI3E, XPIEE, XPIOP, XPIPCOM, XPMISC, XPRD, XPSDOCS, XPSPRNG

CLASSIFICATION SYMBOLS DEFINING EXTENT OF THE SEARCH:

IPC:

CPC: C23C14/35, H01J37/3408, H01J37/345, H01J37/3455, H01J37/3464, H01J37/347

FI/F-TERMS:

KEYWORDS OR OTHER ELEMENTS FEATURING THE INVENTION: rayleigh instability, capillary instability, cascading decay, cascading fission, nanoparticles, magnetron sputtering, nanopowder, rotation rate, droplets, involution